

Title (en)

METHOD FOR PRODUCING AN Emitter ELECTRODE FOR A CRYSTALLINE SILICON SOLAR CELL AND CORRESPONDING SILICON SOLAR CELL

Title (de)

VERFAHREN ZUR HERSTELLUNG EINER Emitter-ELEKTRODE FÜR EINE KRISTALLINE SILIZIUMSOLARZELLE UND ENTSPRECHENDE SILIZIUMSOLARZELLE

Title (fr)

PROCÉDÉ DE RÉALISATION D'UNE ÉLECTRODE ÉMETTEUR DESTINÉE À UNE PILE SOLAIRE CRISTALLINE AU SILICIUM ET PILE SOLAIRE AU SILICIUM CORRESPONDANTE

Publication

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Application

**EP 10741995 A 20100812**

Priority

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- EP 2010061797 W 20100812

Abstract (en)

[origin: CA2771013A1] The invention relates to a method for producing a front-side emitter electrode as a front contact for a silicon solar cell on a silicon wafer, wherein a recess is generated in the front side thereof. A front-side n-doped silicon layer and an antireflection layer are then generated. A paste is then introduced into the recess by means of an inkjet printer, said paste comprising electrically conductive metal particles and corrosive glass frit etching through the antireflection layer to the n-doped silicon layer and electrically contacting the same. Electrically conductive front contact metal is subsequently galvanically deposited in the recess on the tempered paste as a front contact.

IPC 8 full level

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Citation (search report)

See references of WO 2011018507A2

Citation (examination)

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- COLE A ET AL: "Fine-Line Screen Printing In Large Area Laser Grooved, Buried Contact Silicon Solar Cells", 23RD EUROPEAN PHOTOVOLTAIC SOLAR ENERGY CONFERENCE, EU PVSEC ; PROCEEDINGS OF THE INTERNATIONAL CONFERENCE, HELD IN VALENCIA, SPAIN, 1 - 5 SEPTEMBER 2008, 1 September 2008 (2008-09-01), pages 1677 - 1681, XP040529107, ISBN: 978-3-936338-24-9

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SG 178373 A1 20120329; TW 201130149 A 20110901; US 2012204946 A1 20120816; WO 2011018507 A2 20110217;  
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MX 2012001900 A 20100812; SG 2012009643 A 20100812; TW 99127155 A 20100813; US 201213371139 A 20120210